5-27-03

RECEWED MAY 3 0 2003

TC 1700

Docket No.: 8055/0K324U50

(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re Patent Application of:

Juei-Hua Lin

Application No.: 10/091,710

Group Art Unit: 1775

Filed: March 5, 2002

Examiner: Andrew T. PIZIALI

Confirmation No.: 7465

For: ANTI-REFLECTIVE GLASS SURFACE WITH IMPROVED CLEANABILITY

AMENDMENT

Box Non-Fee Amendment

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action dated February 24, 2003 (Paper No.3), please amend the above-identified U.S. patent application as follows:

In the Specification

Please amend the Specification pursuant to 37 C.F.R. § 1.121 as follows (see the accompanying "marked up" version pursuant to § 1.121).

Page 2, beginning on line 17, please amend the paragraph to read as follows:

U.S. Patent No. 5,120,605 to Zuel et al. discloses combining surface structures through both diffusion etching and anti-reflective etching to provide a low reflectance, high clarity

M:\8055\0K324\00001642.DOC